

# Simulating the Absorption and Emission Process in Ti:Sapphire

Ze Ouyang July 14<sup>th</sup> , 2023



- pumping laser: ~5ns, 250mJ, 532nm
- gain material: ~1cm, light beam radius of 0.15cm

absorption cross section: 6.4e-20 cm<sup>2</sup>

emission cross section: 4e-19 cm<sup>2</sup>



Intensity 
$$I: W/cm^2$$
  
 $g = \frac{1}{z} \frac{dI}{dz} \longrightarrow g = \frac{1}{z} \frac{dF}{dz} \longrightarrow F(z) = F(0)e^{gz}$   
Fluence  $F: J/cm^2$ 

suppose the pumping laser of a  $\delta$ -function

## Absorption process





Fluence with the length of the material





#### **Emission process**





## **Emission process**

method: To make it independent with time, cut it into pieces of fluence slices



each pixel goes through the amplified process successively

## after amplification



### convert to intensity



## **Emission process**



## leave out the refraction index of the gain material?

the cross section is given in page 20 in the article